

**Search Notes**

Application No.

10/630,301

Examiner

W. David Coleman

Applicant(s)

HILL ET AL.

Art Unit

2823

**SEARCHED**

Class	Subclass	Date	Examiner

**INTERFERENCE SEARCHED**

Class	Subclass	Date	Examiner

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
EAST 1.4.2 Applicants claim a metal mask and process eliminating photoresist. Only performed text search in EAST.	1/25/2005	WDC